

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Koji SHIGEMURA et al.

Application No. 10/718,640

Group Art Unit: 2879

Confirmation No. 1164

Filed: November 24, 2003

Examiner: Natalie K. Walford

For: EVAPORATION MASK, METHOD OF FABRICATING ORGANIC
ELECTROLUMINESCENT DEVICE USING THE SAME, AND ORGANIC
ELECTROLUMINESCENT DEVICE

APPLICANTS' STATEMENT OF SUBSTANCE OF INTERVIEWS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The Interview Summary faxed on October 4, 2007, and mailed on October 11, 2007, for the telephone interview conducted on October 4, 2007, is acknowledged. Also, the Interview Summary faxed on October 29, 2007, for the telephone interview conducted on October 29, 2007, is acknowledged. The applicants' statement of the substance of the interviews required by MPEP 713.04 is as follows.

On October 4, 2007, a telephone interview initiated by the undersigned attorney was conducted with Examiner Natalie K. Walford. During the interview, the attorney pointed out that the Examiner's statement on page 17 of the Final Office Action of September 11, 2007, that "the deformation process, as disclosed by Mizuguchi, is similar to Applicant's claimed limitation of 'drawing taut by application of tension'[]" is not an adequate response to the applicants' arguments on page 14 of the Request for Reconsideration of May 21, 2007, with respect to the "tension" features of independent claims 1, 49, and 51, particularly since the deformation in Mizuguchi is caused by compressive stress produced by thermal expansion as pointed out in those arguments. As the attorney pointed out during the interview, the compressive stress disclosed by Mizuguchi is the opposite of the "tension" recited in claims 1, 49, and 51. The

Examiner said that she agreed with the attorney, and said that she would consult her supervisor to see how to handle the matter.

Later that same day, October 4, 2007, the Examiner called the attorney back and said that she and her supervisor had decided to reopen prosecution, and that the attorney should receive a new Office Action in one to three weeks. The Examiner then faxed the Interview Summary for the interview of October 4, 2007, to the attorney, stating as follows in the Interview Summary:

The Applicant's representative and the Examiner discussed how the Prior Art differed from the instant application. Mizuguchi teaches that the mask is compressed, which teaches away from Applicant's invention of the mask being drawn taut. The Examiner agreed to reopen prosecution.

On October 19, 2007, the attorney left a voice mail message for Examiner asking about the status of the new Office Action, and asking the Examiner to confirm that the new Office Action will be a non-final Office Action.

On October 22, 2007, Examiner left a voice mail message for the attorney stating that the new Office Action would be mailed out soon, and that the new Office Action will be a non-final Office Action.

On October 26, 2007, the attorney left a voice mail message for the Examiner asking about the status of the new Office Action, and indicating that the applicants would like to receive something in writing before November 1, 2007, confirming that a new Office Action will be issued and that the new Office Action will be a non-final Office Action.

On October 29, 2007, a telephone interview initiated by the attorney was conducted with Examiner Walford, during which the Examiner indicated that a non-final Office Action had been counted that morning, but had not yet been mailed. Later that day, the Examiner faxed the Interview Summary for the interview of October 29, 2007, to the attorney stating as follows in the Interview Summary:

As per the conversation, a non-final office action has been counted on October 29, 2007, but not yet mailed. The Applicant should receive the action soon.

Respectfully submitted,

STEIN, MCEWEN & BUI, LLP

Date: 10/30/07

By:



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